

L Number	Hits	Search Text	DB	Time stamp
1	12187	Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))	USPAT; EPO; JPO	2003/02/22 15:44
5	40576	(oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet)	USPAT; EPO; JPO	2003/02/22 16:14
9	611	((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) and ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 15:45
16	75	((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) same ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 15:46
23	59	((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) same ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet))) and @ad<19990422	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:24
30	20	((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) same ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet))) and @rlad<19990422	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:24
37	61	((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) same ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet))) and @ad<19990422) ((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) same ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet))) and @rlad<19990422)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 15:47
44	6831	(oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2"))	USPAT; EPO; JPO	2003/02/22 16:15
48	159	((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) and ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2"))))	USPAT; EPO; JPO	2003/02/22 16:15
52	10	((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) same ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2"))))	USPAT; EPO; JPO	2003/02/22 16:20
56	45168	((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet)) ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2"))))	USPAT; EPO; JPO	2003/02/22 16:20
60	88858	(gate adj2 (oxide dioxide dielectric insulation insulator insulating isolation isolating))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:22
67	102476	PZT PLZT BST titanate tantalate niobate ferroelectric perovskite	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:23
74	1042	((gate adj2 (oxide dioxide dielectric insulation insulator insulating isolation isolating))) near12 ((Ta2O5 or (Ta?sub.? adj O?sub.?) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) (PZT PLZT BST titanate tantalate niobate ferroelectric perovskite))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:23

81	57	((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet)) ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2")))) and (((gate adj2 (oxide dioxide dielectric insulation insulator insulating isolation isolating))) near12 ((Ta2O5 or (Ta?sub.? adj O?sub.?)) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) (PZT PLZT BST titanate tantalate niobate ferroelectric perovskite)))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:23
88	26	(((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet)) ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2")))) and (((gate adj2 (oxide dioxide dielectric insulation insulator insulating isolation isolating))) near12 ((Ta2O5 or (Ta?sub.? adj O?sub.?)) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) (PZT PLZT BST titanate tantalate niobate ferroelectric perovskite))) and @ad<19990422	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:24
95	14	(((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet)) ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2")))) and (((gate adj2 (oxide dioxide dielectric insulation insulator insulating isolation isolating))) near12 ((Ta2O5 or (Ta?sub.? adj O?sub.?)) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) (PZT PLZT BST titanate tantalate niobate ferroelectric perovskite))) and @rlad<19990422	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:24
102	30	((((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet)) ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2")))) and (((gate adj2 (oxide dioxide dielectric insulation insulator insulating isolation isolating))) near12 ((Ta2O5 or (Ta?sub.? adj O?sub.?)) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) (PZT PLZT BST titanate tantalate niobate ferroelectric perovskite))) and @ad<19990422) (((((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 (water wet)) ((oxidiz\$3 or oxidis\$3 or oxidation anneal\$4) near10 ((hydrogen "H.sub.2") near3 (oxygen "O.sub.2")))) and (((gate adj2 (oxide dioxide dielectric insulation insulator insulating isolation isolating))) near12 ((Ta2O5 or (Ta?sub.? adj O?sub.?)) or ("Ta.sub.2O.sub.5") or ((tantalum or ditantalum) adj (oxide pentaoxide pentoxide))) (PZT PLZT BST titanate tantalate niobate ferroelectric perovskite)))) and @rlad<19990422)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/02/22 16:24